

# surface science

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Prof. Manos Mavrikakis, 2010 Engineering Hall, University of Wisconsin at Madison, 1415 Engineering Drive, Madison, WI 53706, USA  
Tel.: 608 262 9053; Fax: 608-262-9053; E-mail: surfacesci@che.wisc.edu

## Editors

Professor Fumio Komori  
Institute for Solid State Physics  
University of Tokyo  
5-1-5 Kashiwanoha, Kashiwa  
Chiba 277-8581, Japan  
Tel.: +81 4 7136 3310  
Fax: +81 4 7136 3474  
E-mail: surface.science@issp.u-tokyo.ac.jp

Professor Klaus Wandelt  
Institut für Physikalische und Theoretische  
Chemie der Universität Bonn  
Wegelerstraße 12  
D-53115 Bonn  
Germany  
Fax: +49-228-732515  
E-mail: surface.science@thch.uni-bonn.de

Professor H P. Steinrueck  
Lehrstuhl für Physikalische Chemie II,  
Friedrich-Alexander-Universität  
Erlangen-Nürnberg, Egerlandstrasse 3,  
D-91058, Erlangen,  
Germany  
Ph: +4991318527343  
E-mail: hans-peter.steinrueck@fau.de

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- reactivity of surfaces as related to various applied areas including heterogeneous catalysis, chemistry at electrified interfaces, and semiconductors functionalization
- phenomena at interfaces relevant to energy storage and conversion, and fuels production and utilization
- surface reactivity for environmental protection and pollution remediation
- interactions at surfaces of soft matter, including polymers and biomaterials.

Both experimental and theoretical work, including modeling, is within the scope of the journal. Work published in Surface Science reaches a wide readership, from chemistry and physics to biology and materials science and engineering, providing an excellent forum for cross-fertilization of ideas and broad dissemination of scientific discoveries.

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